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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/684,930	10/13/2003	Nathaniel R. Quick	2003-0026	6377
7590	09/09/2004			EXAMINER ANYA, IGWE U
Robert F. Frijouf Frijouf, Rust & Pyle, P.A. 201 East Davis Boulevard Tampa, FL 33606			ART UNIT 2825	PAPER NUMBER

DATE MAILED: 09/09/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary	Application No.	Applicant(s)	
	10/684,930	QUICK, NATHANIEL R.	
	Examiner Igwe U. Anya	Art Unit 2825	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) Responsive to communication(s) filed on 13 October 2003.
- 2a) This action is FINAL. 2b) This action is non-final.
- 3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) Claim(s) 1-30 is/are pending in the application.
- 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
- 5) Claim(s) 1-22 is/are allowed.
- 6) Claim(s) 23-30 is/are rejected.
- 7) Claim(s) 24 is/are objected to.
- 8) Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) The specification is objected to by the Examiner.
- 10) The drawing(s) filed on 13 October 2003 is/are: a) accepted or b) objected to by the Examiner.
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

- 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) All b) Some * c) None of:
1. Certified copies of the priority documents have been received.
 2. Certified copies of the priority documents have been received in Application No. _____.
 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- 1) Notice of References Cited (PTO-892)
- 2) Notice of Draftsperson's Patent Drawing Review (PTO-948)
- 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)
Paper No(s)/Mail Date 1/30/04.
- 4) Interview Summary (PTO-413)
Paper No(s)/Mail Date. _____.
- 5) Notice of Informal Patent Application (PTO-152)
- 6) Other: _____.

DETAILED ACTION

Claim Objections

1. Claim 24 is objected to because of the following informalities: “one of the first and second thermal energy beams” in line 1, lacks antecedent basis. Appropriate correction is required.

Claim Rejections - 35 USC § 102

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

(a) the invention was known or used by others in this country, or patented or described in a printed publication in this or a foreign country, before the invention thereof by the applicant for a patent.

3. Claims 23 – 30 are rejected under 35 U.S.C. 102(a) as being anticipated by Salama et al. (Compound Semiconductors, 2003 International Symposium).
4. Salama et al. teach a method for making a nano-size conductive element within a wide-band gap semiconductor substrate, comprising, providing a wide-band gap semiconductor substrate and focusing a laser beam into a region internal the wide-band gap semiconductor substrate for heating the region internal of the wide-band gap semiconductor substrate for changing the structure of the wide-band gap semiconductor to provide the nano-size conductive element. Providing a doping atmosphere for the wide-band gap semiconductor substrate, wherein the doping atmosphere is selected from the group consisting of a gaseous metallo-organic doping atmosphere, a vapor metallo-organic doping atmosphere for laser doping the wide-band gap semiconductor substrate, and the doping atmosphere is selected from the group consisting of nitrogen

or phosphorous for creating an N-type semiconductor, and aluminum, or boron for creating a P-type semiconductor. Projecting a thermal energy beam onto the wide-band gap semiconductor substrate for heating the wide-band gap semiconductor substrate for changing the structure of the wide-band gap semiconductor with the doping atmosphere to provide the nano-size element. Projecting a thermal energy beam onto a portion of the nano-size conducting element for heating the portion of the nano-size conducting element in the presence of the doping atmosphere for changing the structure of the portion of the nano-size conducting element to provide the nano-size element (pp 102 – 103).

5. Claims 1 – 22 are allowable, because prior art does not teach directing a second thermal energy on a second portion of a wide band gap semiconductor substrate to form a nano-size second element of a semiconductor component.

6. Prior art considered, but not used in the rejection include Lieber et al. (USPAP 2003/0089899), Auner et al. (USPAP 2004/0145053), and Quick (US Patent 6670693).

7. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Igwe U. Anya whose telephone number is (571) 272-1887. The examiner can normally be reached on M - F 8:30am - 5:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew S. Smith can be reached on (571) 272-1907. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Art Unit: 2825

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Igwe U. Anya
Examiner
Art Unit 2825

IA

August 31, 2004


CARIDAD EVERAULT
PRIMARY EXAMINER